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Alan J. Kasper T 202-663-7903 akasper@sughrue.com

July 15, 2003



MAIL STOP PATENT APPLICATION

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Re:

Application of Kouji TAKAHASHI and Hiroo ITOH

GLASS SUBSTRATE FOR A MASK BLANK, METHOD OF PRODUCING A GLASS SUBSTRATE FOR A MASK BLANK, MASK BLANK, METHOD OF PRODUCING THE MASK BLANK, TRANSFER MASK, AND METHOD OF

PRODUCING A TRANSFER MASK Assignee: HOYA CORPORATION

Our Ref. Q76587

Dear Sir:

Attached hereto is the application identified above comprising thirty (30) sheets of the specification (Japanese Language), including the claims and abstract and three (3) sheets of drawings. The requisite U.S. Government Filing Fee, executed Declaration and Power of Attorney, Assignment and English Translation will be submitted at a later date.

The Government filing fee is calculated as follows:

Total claims Independent claims Base Fee	<u>19</u> - 20 <u>1</u> - 3	=	X X	\$18.00 \$84.00	= _	\$.00 \$.00 \$750.00
TOTAL FEE						\$750.00



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Priority is claimed from:

Country

Application No

Filing Date

JAPAN

208049/2002

July 17, 2002

The priority document will be filed at a later date.

Respectfully submitted, SUGHRUE MION, PLLC

Attorneys for Applicant

В

Alan J. Kasper

Registration No. 25,426

SUGHRUE MION, PLLC Telephone: (202) 293-7060

Facsimile: (202) 293-7860

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PATENT TRADEMARK OFFICE

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